IFW

Inhereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail, in an envelope addressed to: MS AF, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date shown below.

Dated: July 14, 2005 Signature:

PATE TRACES

(Michael R. Hull)

Docket No.: 29936/39485 (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Kwan Yong Lim et al.

Application No.: 10/615,478

Art Unit: 2829

Filed: July 8, 2003

Examiner: Asok K. Sarkar

For: METHOD OF FORMING GATE IN

SEMICONDUCTOR DEVICE

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Commissioner:

INTRODUCTORY COMMENTS

In response to the non-final office action dated April 14, 2005, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments in support of the allowability of this application begin on page 5 of this paper.